## IAP5 Rec'd PCT/PTO 07 FEB 2006

Docket No.: 034299-682

10/567889

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANT:

Marc REBAROT, et al.

SERIAL NO.:

unassigned

FILING DATE:

herewith

TITLE:

Method for Producing Inclined Flank Patterns by Photolithography

**EXAMINER:** 

**UNASSIGNED** 

**ART UNIT:** 

**UNASSIGNED** 

COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria VA 22313-1450

## PRELIMINARY AMENDMENT

Dear Sir:

Prior to examination, please amend the above-identified application as follows:

Amendments to the Specification begin on page 2 of this paper.

Amendments to the Claims are reflected in the listing of claims, which begins on page 3 of this paper.

Remarks / Arguments begin on page 6 of this paper.